# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: James J. Finley et al.

Appl. No.: to be assigned

Filed: herewith

Title: DURABLE SPUTTERED METAL OXIDE COATING

Group Art Unit:

Examiner:

Docket No.: 1074D2

### PRELIMINARY AMENDMENT

Commissioner for Patents Washington, D.C. 20231

Sir:

Please amend the above-identified application as follows:

## IN THE SPECIFICATION

After the title and before the paragraph entitled "BACKGROUND", insert the following paragraph:

### Related Application

This is a divisional of U.S. Patent Application Serial No. 08/508,408, filed on July 28, 1995, now U.S. Patent No. 6,346,174 B1; which is a divisional of U.S. Patent Application Serial No. 08/151,229, filed on November 12, 1993, now abandoned.

#### IN THE CLAIMS

Cancel claims 1-20 and add the following claims 21-43.

--21. A coated product comprising a substrate and a film sputtered from a metal cathode target in an atmosphere comprising inert gas and reactive gas, the metal in the metal cathode target having a reactive gas switch point, wherein the concentration of the reactive gas during sputtering is below the reactive gas switch point such that the metal target is sputtered in a metallic mode to deposit a metal film having an amorphous structure defined as an amorphous metal film.

- 22. The product in accordance with claim 21, wherein the metal of the metal cathode target is selected from titanium, zirconium, tantalum, hafnium, niobium, vanadium and mixtures thereof.
- 23. The product in accordance with claim 22, wherein the metal of the metal cathode target is selected from titanium and zirconium.
- \$24.\$ The product in accordance with claim 23, wherein the metal of the metal cathode target is titanium.
- 25. The product in accordance with claim 21, wherein the metal film has a thickness ranging from 100  $\rm \mathring{A}$  to 1500 $\rm \mathring{A}$ .
- 26. The product in accordance with claim 5, wherein the metal film has a thickness ranging from 200  $\rm \mathring{A}$  to 700 $\rm \mathring{A}$ .
- 27. The product in accordance with claim 21, wherein the reactive gas is selected from oxygen, nitrogen and mixtures thereof.
- 28. The product in accordance with claim 27, wherein the reactive gas is oxygen.
- 29. The product in accordance with claim 27, wherein the inert gas is argon.
- $\,$  30. The product in accordance with claim 21, wherein the inert gas is argon.
- 31. The product in accordance with claim 30, wherein the reactive gas is oxygen.
- 32. The product in accordance with claim 31, wherein the substrate is glass, the metal in the metal film is titanium.

- 33. The product in accordance with claim 31, wherein the atmosphere comprises argon and up to 30 percent oxygen.
- 34. The product in accordance with claim 33, wherein the atmosphere comprises 2 to 15 percent oxygen.
- 35. The product in accordance with claim 21, wherein the substrate is glass.
- 36. The product in accordance with claim 21, wherein the metal film is thermally oxidized.
- 37. The product in accordance with claim 36, wherein the metal film is heated to at least  $400^{\circ}$ C.
- 38. The product in accordance with claim 36, further comprising a metal oxide film deposited on the metal film prior to thermal oxidation of the metal film.
- 39. The product in accordance with claim 38, wherein the metal oxide film has a thickness ranging from 40  $\mathring{\rm A}$  to 120 $\mathring{\rm A}$ .
- 40. The product in accordance with claim 38, wherein the substrate is glass, the metal in each film is titanium, the density of the metal oxide film is 4 grams per cubic centimeter and the refractive index of the metal oxide film is 2.5
- 41. The product in accordance with claim 38, wherein the metal in each film is independently selected from titanium, zirconium, tantalum, hafnium, niobium, vanadium and mixtures thereof.
- 42. The product in accordance with claim 41, wherein the metal in each film is independently selected from titanium and zirconium.

43. A coated article comprising a glass substrate, a first titanium oxide film formed by thermally oxidizing an amorphous sputtered titanium metal film deposited from a titanium metal cathode target in an atmosphere comprising argon and oxygen below a reactive switch point of the titanium metal cathode target, and a second titanium oxide film deposited over the first titanium oxide film.—

#### REMARKS

Claims 1-20 are canceled and claims 21-43 are added. Support for claims 21-43 is found, among other places, in the originally filed claims and in the drawing. Based on the foregoing, applicant respectfully requests admittance and consideration of claims 21-43.

Respectfully submitted,

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